Thulium-based EUV Drive Lasers Scalable to Near-MW Average Powers

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Introduction

New Architectures for PW-Scale High Peak Power Lasers Scalable to Near-MW Average Powers and Their Application to EUV Generation





At the November 2018 EUV Source Workshop, we introduced novel high average power laser architectures based upon LLNL/ELI-Beamlines HAPLS/L3 laser:

- SHARC (Scalable High-power Advanced Radiography Capability):
 - diode-pumped Nd:Glass, 1-um wavelength
 - 150-J/150-fs/10-Hz
 - for laser-driven secondary x-rays/neutrons
- BAT (Big Aperture Thulium):
 - diode-pumped Tm:YLF, 1.9-um wavelength
 - 30-J/100-fs/10-kHz
 - for laser-driven electron/positron colliders

And we presented promising preliminary CE estimates of 2-um EUV drive lasers on Sn droplets showing on-par with CO_2 .

For this 2019's EUVL Workshop, we present results of detailed laser systems engineering modeling* for EUV-tailored design points of the BAT architecture.

*funded by LLNL LDRD office.





Pushing the frontiers of high-power applications and high-intensity science requires next-generation high repetition-rate high-energy solid state lasers.

ELI L3-High-repetition-rate Advanced Petawatt Laser System (L3-HAPLS) is the only PW-class DPSSLP laser operational today

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June 2	018: HA	APLS F	inal Re	eview	

July 2018

FIRST SHOT

Requirement	Specification		
Energy at 820nm	≥30 J (Phase 2)		
Pulse Length	≤30 fs		
Peak Power	≥1 PW		
Pre-pulse Power Contrast	$\leq 10^{-9} \leq c \leq 10^{-11}$		
Energy Stability	0.6% rms		
Technology	DPSSL pumped Ti:sapphire CPA		
Repetition Rate	10 Hz (Phase 2)		
Power Consumption	<150 kW		

For first experiments HAPLS was configured for ~1/2 PW at 3¹/₃Hz with a full-aperture pulse duration of 26fs



HAPLS is an operational, industry-grade "set and forget" laser system, and is a stepping stone for exploring the science of secondary sources







LLNL's BAT-Class laser architecture sets a new standard for high average power lasers with high true wall-plug efficiency



Why Tm:YLF? Long gain-lifetime and efficient diodepumping with COTS diodes



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Stored energy can be extracted from laser medium with a high fluence single pulse, or multiple low-fluence pulses within the radiative lifetime



Multi-pulse extraction reduces the effective fluence in the laser system and therefore moves the operating point into a manageable regime for low cross-section materials



Big Aperture Thulium Laser Concept

Collider: 30J, 100fs, 0.3PW, 10kHz LWFA testbeds: 240J, 240fs, 1.0PW, 100Hz

300,000 W Average Power

- BAT is an extension of HAPLS Chirped-Pulse-Amplification architecture
 - 14X improvement in true wallplug efficiency
- Tm:YLF laser media
 - 1900 nm emission pumped at 790 nm
 - Two-for-one pumping = low quantum defect
 - Superior thermal wave front (- dn/dT)
 - Larger ponderomotive force

20m

Material exists today

True CW pumping

- Long lifetime (15 ms) & multi-pulse extraction
- Efficient extraction at low fluence per pulse
- 1000X average power with only 2X more diodes!

The BAT technology is the game changer to drive LPA with up to 300kW of average power per stage



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By operating in a steady-state, multi-pulse extracted BAT lasers optimize efficiency AND pulse-to-pulse stability

Continuous Pumping and

Continuous Cooling

Pulsed Pumping and Pulsed Cooling





We have developed an EUV-BAT design that consists of a diode-pumped surfacecooled multi-slab amplifier in a 4-pass polarization switched architecture







Our EUV-BAT design point has minimal distortion in amplification: output pulse accurately follows seed pulse





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The EUV-BAT design point has minimal distortion in amplification: precise pulse shaping





The EUV-BAT design point has minimal distortion in amplification: precise pulse shaping





The EUV-BAT design point has minimal distortion in amplification: precise pulse shaping





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Our EUV-BAT design allows for amplification of a pre-pulse in the same laser







EUV-BAT model results: dual pulse output with sub-us pre-pulse and main-pulse





Tm:YLF can support very short (even sub-ps) pulse duration pre-pulse





EUV-BAT model results: rep-rate downscaling at fixed energy, and up-scaling at fixed power



- An as-built amplifier may be run at different power levels and repetition rates than its design point
 - Amplifiers most efficient near design point
- Higher rep-rate \rightarrow constant average power tuning
 - Completely electronic, maintains efficiency
- Lower rep-rate → constant energy tuning
 - Efficiency can re-optimized at new operating point by down-sizing beam size in laser



The EUV-BAT design is very flexible in its design point, and an as-built system can be tuned over a wide range of rep-rates. A research system would benefit from over-specing (e.g. 4J vs 1J @ 25-kHz) to avoid reconfiguration. Factory systems can be designed to optimum specs.



Diode-pumped Solid-State Thulium Lasers are an attractive candidate for next-gen EUV drivers



- We have developed a 100-kW BAT point design tailored for EUV application
- Design scalable to even higher powers, but unclear if target supports
- Steady-state diode pumping allows for very high pulse-to-pulse energy stability
- Flexible and robust pulse shaping
- Pre- and main-pulse in common amplifier

System-level CE, exposure, and cost trade study will layout development paths:

- Large-scale ensemble modeling of:
 - target model for CE and other important features (next talk)
 - Hydrodynamic (ALEAMR) model of droplet-to-droplet interaction
- Laser system modeling and optimization around ensemble optima
- In parallel, key risk-mitigation and reduction to practice of laser technology

